

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
3 January 2002 (03.01.2002)

PCT

(10) International Publication Number
WO 02/00085 A3

- (51) International Patent Classification⁷: **B32B 5/22**, (74) Agents: **FRANK, J., William, III** et al.; S. C. Johnson & Son, Inc., 1525 Howe Street, Racine, WI 53403 (US).
A47L 13/16
- (21) International Application Number: PCT/US01/19842 (81) Designated States (*national*): AU, BR, CA, CN, CZ, HU, JP, KR, MX, NZ, PL, RU, SG, SK, UA, ZA.
- (22) International Filing Date: 22 June 2001 (22.06.2001)
- (25) Filing Language: English (84) Designated States (*regional*): European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, TR).
- (26) Publication Language: English
- (30) Priority Data: Published:
09/605,944 28 June 2000 (28.06.2000) US — with international search report
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30 May 2002
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(54) Title: PARTICLE ENTRAPMENT SYSTEM

(57) Abstract: A cleaning sheet for cleaning and removing particles from a surface is disclosed. The sheet includes a particle retention layer including an electret material for collecting and retaining the particles. The sheet also includes an outer layer covering at least a portion of the particle retention layer. The outer layer comprises a low dust retention material and includes a surface having a plurality of apertures formed therethrough.